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APPLICATION NO. FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
10/092,795 03/06/2002		Padmapani C. Nallan	7017/ETCH/CONE 3410		
32588	7590 09/24/2003	,			
APPLIED MATERIALS, INC.			EXAMINER		
	T BLVD. M/S 2061 ARA, CA 95050		NGUYEN, TUAN H		
			ART UNIT	PAPER NUMBER	
			2813		
			DATE MAILED: 09/24/2003		

Please find below and/or attached an Office communication concerning this application or proceeding.

					SAV				
	1	Application	on No.	Applicant(s)					
Office Action Summary		10/092,79	5	NALLAN ET AL.					
		Examiner		Art Unit					
		Tuan H. N	· ·	2813					
The MAILING DATE of this communication app ars on the cover sheet with the corresponding address Period for Reply									
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status									
1)⊠	Responsive to communication(s) filed	on <u>22 <i>July 2003</i></u> .							
2a)⊠	This action is FINAL . 2b)	☐ This action is	non-final.						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.									
Disposition of Claims									
4)⊠	Claim(s) 1-4 and 6-17 is/are pending in the application.								
5\ \ \	4a) Of the above claim(s) is/are withdrawn from consideration.								
	Claim(s) <u>17</u> is/are allowed.								
·	Claim(s) 1, 2, 4 and 6-14 is/are rejected.								
·	Claim(s) 3,15 and 16 is/are objected to.								
8) Claim(s) are subject to restriction and/or election requirement.									
Application Papers ON The energification is objected to by the Examiner									
9) ☐ The specification is objected to by the Examiner. 10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.									
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).									
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.									
If approved, corrected drawings are required in reply to this Office action.									
12) The oath or declaration is objected to by the Examiner.									
Priority under 35 U.S.C. §§ 119 and 120									
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).									
a) ☐ All b) ☐ Some * c) ☐ None of:									
1. Certified copies of the priority documents have been received.									
	2. Certified copies of the priority documents have been received in Application No								
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 									
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).									
a) The translation of the foreign language provisional application has been received. 15) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.									
Attachment(s)									
2) Notice	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO- mation Disclosure Statement(s) (PTO-1449) Paper			y (PTO-413) Paper No(Patent Application (PT6					

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Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1, 2, 4, 6-14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Moise et al..

Moise et al., particularly paragraph [0097] and step 4 in table on page 6; paragraphs [0159], [0160] on page 11, paragraphs [0167] on page 12, and paragraph [0173] on page 13 disclose substantially the claimed method of etching a layer of dielectric PZT having a dielectric constant greater than 4 by exposing the PZT dielectric layer 608 to a plasma comprising a reducing gas of oxygen and a halogen containing gas of chlorine. See also for the etching of PZT or BST dielectric layer using Cl₂ plus O₂.

Moise et al. does not particularly use CO as an oxygen source; however, in table on page 11, paragraph [0160], Moise et al. suggests the alternating oxygen source such as either O₂ or CO.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to have replaced O₂ with CO as a gas source in the process of

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plasma etching the dielectric layer, since the substitution of art recognized equivalence as suggested by Moise et al. would have been within the level of those skilled in the art.

With respect to claims 8-14, it would have been also obvious to those skill in the art to select a suitable control parameter such as power, flow rate, pressure for obtaining the best result

Allowable Subject Matter

Claim 17 is allowed.

Claims 3, 15, 16 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The following is a statement of reasons for the indication of allowable subject matter: None of the references of record teaches or suggests the claimed method for etching hafnium-oxide by plasma using chlorine and CO.

Response to Arguments

Applicant's arguments filed 7/22/03 have been fully considered but they are not persuasive. Contrary to the applicant's argument in his Remarks, Section D that Moise does not teach, show or suggest the use of CO together with Cl₂ for etching a high dielectric constant layer. Moise uses the Cl₂ with O₂ for etching the PZT; however, it would have been obvious to those skilled in the art to replace O₂ with CO as suggested by Moise on paragraph [0160], in the table that summarizes "various convenient gases categorized according to function and which may be used as <u>replacements or additives</u>" as recognized by the applicant.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tuan H. Nguyen whose telephone number is 703-308-

2550. The examiner can normally be reached on 9AM-5:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead Jr. can be reached on 703-308-4940. The fax phone numbers for the organization where this application or proceeding is assigned are 703-872-9318 for regular communications and 703-872-9319 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

Tuan H. Nguyen
Primary Examiner
Art Unit 2813

TN September 23, 2003